

LMG1205 100-V, 1.2-A to 5-A, Half Bridge GaN Driver with Integrated Bootstrap Diode

1 Features

- Independent high-side and low-side TTL logic inputs
- 1.2-A peak source, 5-A sink current
- High-side floating bias voltage rail operates up to 100 VDC
- Internal bootstrap supply voltage clamping
- Split outputs for adjustable turnon, turnoff strength
- 0.6-Ω pulldown, 2.1-Ω pullup resistance
- Fast propagation times (35 ns typical)
- Excellent propagation delay matching (1.5 ns typical)
- Supply rail undervoltage lockout
- Low power consumption

2 Applications

- Current-fed push-pull converters
- Half and full-bridge converters
- Synchronous buck converters
- Two-switch forward converters
- Forward with active clamp converters

3 Description

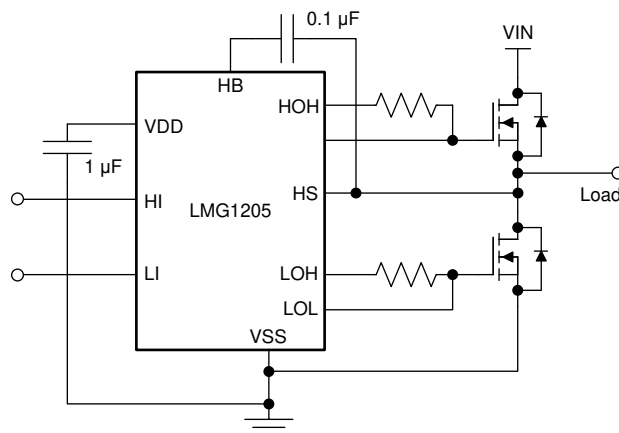
The LMG1205 is designed to drive both the high-side and the low-side enhancement mode Gallium Nitride (GaN) FETs in a synchronous buck, boost, or half-bridge configuration. The device has an integrated 100-V bootstrap diode and independent inputs for the high-side and low-side outputs for maximum control flexibility. The high-side bias voltage is generated using a bootstrap technique and is internally clamped at 5 V, which prevents the gate voltage from exceeding the maximum gate-source voltage rating of enhancement mode GaN FETs. The inputs of the LMG1205 are TTL logic compatible and can withstand input voltages up to 14 V regardless of the VDD voltage. The LMG1205 has split-gate outputs, providing flexibility to adjust the turnon and turnoff strength independently.

In addition, the strong sink capability of the LMG1205 maintains the gate in the low state, preventing unintended turnon during switching. The LMG1205 can operate up to several MHz. The LMG1205 is available in a 12-pin DSBGA package that offers a compact footprint and minimized package inductance.

Device Information⁽¹⁾

PART NUMBER	PACKAGE	BODY SIZE (NOM)
LMG1205	DSBGA (12)	2.00 mm × 2.00 mm

(1) For all available packages, see the orderable addendum at the end of the data sheet.



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Simplified Application Diagram



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4 Revision History

NOTE: Page numbers for previous revisions may differ from page numbers in the current version.

Changes from Revision A (February 2018) to Revision B (April 2023)	Page
• Changed title of data sheet from 80-V to 100-V.....	1
• Added clamping circuit delay time and functional explanation to Section 7.3.3	12
• Changed equation in Section 8.2.2.2	14
Changes from Revision * (March 2017) to Revision A (February 2018)	Page
• Changed title of data sheet	1

5 Pin Configuration and Functions

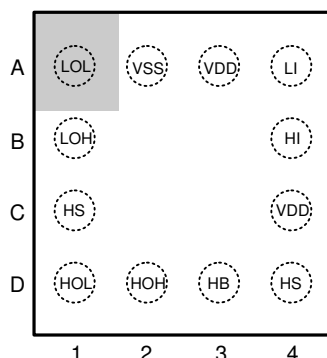


Figure 5-1. YFX Package 12-Pin DSBGA Top View

Table 5-1. Pin Functions

PIN		TYPE (2)	DESCRIPTION
NUMBER	NAME		
A1	LOL	O	Low-side gate driver sink-current output: connect to the gate of the low-side GaN FET with a short, low inductance path. A gate resistor can be used to adjust the turnoff speed.
A2	VSS	G	Ground return: all signals are referenced to this ground.
A3, C4 ⁽¹⁾	VDD	P	5-V positive gate drive supply: locally decouple to VSS using low ESR/ESL capacitor located as close as possible to the IC.
A4	LI	I	Low-side driver control input. The LMG1205 inputs have TTL type thresholds. Unused inputs must be tied to ground and not left open.
B1	LOH	O	Low-side gate driver source-current output: connect to the gate of low-side GaN FET with a short, low inductance path. A gate resistor can be used to adjust the turnon speed.
B4	HI	I	High-side driver control input. The LMG1205 inputs have TTL type thresholds. Unused inputs must be tied to ground and not left open.
C1, D4 ⁽¹⁾	HS	P	High-side GaN FET source connection: connect to the bootstrap capacitor negative terminal and the source of the high-side GaN FET.
D1	HOL	O	High-side gate driver turnoff output: connect to the gate of high-side GaN FET with a short, low inductance path. A gate resistor can be used to adjust the turnoff speed.
D2	HOH	O	High-side gate driver turnon output: connect to the gate of high-side GaN FET with a short, low inductance path. A gate resistor can be used to adjust the turnon speed.
D3	HB	P	High-side gate driver bootstrap rail: connect the positive terminal of the bootstrap capacitor to HB and the negative terminal to HS. The bootstrap capacitor must be placed as close as possible to the IC.

(1) A3 and C4, C1 and D4 are internally connected

(2) I = Input, O = Output, G = Ground, P = Power

6 Specifications

6.1 Absolute Maximum Ratings

over operating free-air temperature range (unless otherwise noted)⁽¹⁾

	MIN	MAX	UNIT
VDD to VSS	−0.3	7	V
HB to HS	−0.3	7	V
LI or HI input	−0.3	15	V
LOH, LOL output	−0.3	VDD + 0.3	V
HOH, HOL output	$V_{HS} - 0.3$	$V_{HB} + 0.3$	V
HS to VSS	−5	93	V
HS to VSS ⁽²⁾	−5	100	V
HB to VSS	0	100	V
HB to VSS ⁽²⁾	0	107	V
Operating junction temperature		150	°C
Storage temperature, T _{stg}	−55	150	°C

- (1) Stresses beyond those listed under *Absolute Maximum Ratings* may cause permanent damage to the device. These are stress ratings only, which do not imply functional operation of the device at these or any other conditions beyond those indicated under *Recommended Operating Conditions*. Exposure to absolute-maximum-rated conditions for extended periods may affect device reliability.
- (2) Device can withstand 1000 pulses up to the value indicated in the table of 100-ms duration and less than 1% duty cycle over its lifetime.

6.2 ESD Ratings

		VALUE	UNIT
V _(ESD) Electrostatic discharge	Human-body model (HBM), per ANSI/ESDA/JEDEC JS-001 ⁽¹⁾	±1000	V
	Charged-device model (CDM), per JEDEC specification JESD22-C101 ⁽²⁾	±500	

- (1) JEDEC document JEP155 states that 500-V HBM allows safe manufacturing with a standard ESD control process.
- (2) JEDEC document JEP157 states that 250-V CDM allows safe manufacturing with a standard ESD control process.

6.3 Recommended Operating Conditions

over operating free-air temperature range (unless otherwise noted)

	MIN	NOM	MAX	UNIT
VDD	4.5		5.5	V
LI or HI input	0		14	V
HS	−5		90	V
HB	$V_{HS} + 4$		$V_{HS} + 5.5$	V
HS slew rate			50	V/ns
Operating junction temperature	−40		125	°C

6.4 Thermal Information

THERMAL METRIC ⁽¹⁾		LMG1205	UNIT
		YFX (DSBGA)	
		12 PINS	
R _{θJA}	Junction-to-ambient thermal resistance	76.8	°C/W
R _{θJC(top)}	Junction-to-case (top) thermal resistance	0.6	°C/W
R _{θJB}	Junction-to-board thermal resistance	12.0	°C/W
ψ _{JT}	Junction-to-top characterization parameter	1.6	°C/W

6.4 Thermal Information (continued)

THERMAL METRIC ⁽¹⁾	LMG1205	UNIT
	YFX (DSBGA)	
	12 PINS	
Ψ_{JB} Junction-to-board characterization parameter	12.0	°C/W

- (1) For more information about traditional and new thermal metrics, see the [Semiconductor and IC Package Thermal Metrics](#) application report.

6.5 Electrical Characteristics

Specifications are $T_J = 25^\circ\text{C}$. Unless otherwise specified: $V_{DD} = V_{HB} = 5\text{ V}$, $V_{SS} = V_{HS} = 0\text{ V}$. No load on LOL and HOL or HOH and HOL ⁽¹⁾.

PARAMETER		TEST CONDITIONS		MIN	TYP	MAX	UNIT
SUPPLY CURRENTS							
I _{DD}	VDD quiescent current	LI = HI = 0 V, V _{DD} = V _{HB} = 4 V	T _J = 25°C	0.09		mA	
			T _J = −40°C to 125°C	0.12			
I _{DDO}	VDD operating current	f = 500 kHz	T _J = 25°C	2		mA	
			T _J = −40°C to 125°C	3			
I _{HB}	Total HB quiescent current	LI = HI = 0 V, V _{DD} = V _{HB} = 4 V	T _J = 25°C	0.10		mA	
			T _J = −40°C to 125°C	0.12			
I _{HBO}	Total HB operating current	f = 500 kHz	T _J = 25°C	1.5		mA	
			T _J = −40°C to 125°C	2.5			
I _{HBS}	HB to VSS quiescent current	HS = HB = 80 V	T _J = 25°C	0.1		μA	
			T _J = −40°C to 125°C	8			
I _{HBSO}	HB to VSS operating current	f = 500 kHz	T _J = 25°C	0.4		mA	
			T _J = −40°C to 125°C	1			
INPUT PINS							
V _{IR}	Input voltage threshold	Rising edge	T _J = 25°C	2.06		V	
			T _J = −40°C to 125°C	1.89	2.18		
V _{IF}	Input voltage threshold	Falling edge	T _J = 25°C	1.66		V	
			T _J = −40°C to 125°C	1.48	1.76		
V _{IHYS}	Input voltage hysteresis			400		mV	
R _I	Input pulldown resistance		T _J = 25°C	200		kΩ	
			T _J = −40°C to 125°C	100	300		
UNDERVOLTAGE PROTECTION							
V _{DDR}	VDD rising threshold		T _J = 25°C	3.8		V	
			T _J = −40°C to 125°C	3.2	4.5		
V _{DDH}	VDD threshold hysteresis			0.2		V	
V _{HBR}	HB rising threshold		T _J = 25°C	3.2		V	
			T _J = −40°C to 125°C	2.5	3.9		
V _{HBH}	HB threshold hysteresis			0.2		V	
BOOTSTRAP DIODE AND CLAMP							
V _{DL}	Low-current forward voltage	I _{VDD-HB} = 100 μA	T _J = 25°C	0.45		V	
			T _J = −40°C to 125°C	0.65			
V _{DH}	High-current forward voltage	I _{VDD-HB} = 100 mA	T _J = 25°C	0.9		V	
			T _J = −40°C to 125°C	1			
R _D	Dynamic resistance	I _{VDD-HB} = 100 mA	T _J = 25°C	1.85		Ω	
			T _J = −40°C to 125°C	3.6			
	HB-HS clamp regulation voltage		T _J = 25°C	5		V	
			T _J = −40°C to 125°C	4.5	5.25		

6.5 Electrical Characteristics (continued)

Specifications are $T_J = 25^\circ\text{C}$. Unless otherwise specified: $V_{DD} = V_{HB} = 5\text{ V}$, $V_{SS} = V_{HS} = 0\text{ V}$.
No load on LOL and HOL or HOH and HOL⁽¹⁾.

PARAMETER		TEST CONDITIONS		MIN	TYP	MAX	UNIT
LOW- and HIGH-SIDE GATE DRIVER							
V _{OL}	Low-level output voltage	I _{HOL} = I _{LOL} = 100 mA	T _J = 25°C	0.06		V	
			T _J = -40°C to 125°C	0.1			
V _{OH}	High-level output voltage V _{OH} = V _{DD} – LOH or V _{OH} = HB – HOH	I _{HOH} = I _{LOH} = 100 mA	T _J = 25°C	0.21		V	
			T _J = -40°C to 125°C	0.31			
I _{OHL}	Peak source current	HOH, LOH = 0 V		1.2		A	
I _{OLL}	Peak sink current	HOL, LOL = 5 V		5		A	

6.6 Switching Characteristics

over operating free-air temperature range (unless otherwise noted)

PARAMETER		TEST CONDITIONS		MIN	TYP	MAX	UNIT
t_{LPHL}	LO turnoff propagation delay	LI falling to LOL falling	$T_J = 25^\circ\text{C}$		33.5		ns
			$T_J = -40^\circ\text{C to } 125^\circ\text{C}$			50	
t_{LPLH}	LO turnon propagation delay	LI rising to LOH rising	$T_J = 25^\circ\text{C}$		35		ns
			$T_J = -40^\circ\text{C to } 125^\circ\text{C}$			50	
t_{HPHL}	HO turnoff propagation delay	HI falling to HOL falling	$T_J = 25^\circ\text{C}$		33.5		ns
			$T_J = -40^\circ\text{C to } 125^\circ\text{C}$			50	
t_{HPLH}	HO turnon propagation delay	HI rising to HOH rising	$T_J = 25^\circ\text{C}$		35		ns
			$T_J = -40^\circ\text{C to } 125^\circ\text{C}$			50	
t_{MON}	Delay matching LO on and HO off	$T_J = 25^\circ\text{C}$			1.5		ns
		$T_J = -40^\circ\text{C to } 125^\circ\text{C}$				8	
t_{MOFF}	Delay matching LO off and HO on	$T_J = 25^\circ\text{C}$			1.5		ns
		$T_J = -40^\circ\text{C to } 125^\circ\text{C}$				8	
t_{HRC}	HO rise time (0.5 V – 4.5 V)	$C_L = 1000\text{ pF}$			7		ns
t_{LRC}	LO rise time (0.5 V – 4.5 V)	$C_L = 1000\text{ pF}$			7		ns
t_{HFC}	HO fall time (0.5 V – 4.5 V)	$C_L = 1000\text{ pF}$			3.5		ns
t_{LFC}	LO fall time (0.5 V – 4.5 V)	$C_L = 1000\text{ pF}$			3.5		ns
t_{PW}	Minimum input pulse width that changes the output				10		ns
t_{BS}	Bootstrap diode reverse recovery time	$I_F = 100\text{ mA}$, $I_R = 100\text{ mA}$			40		ns

(1) Parameters that show only a typical value are ensured by design and may not be tested in production.

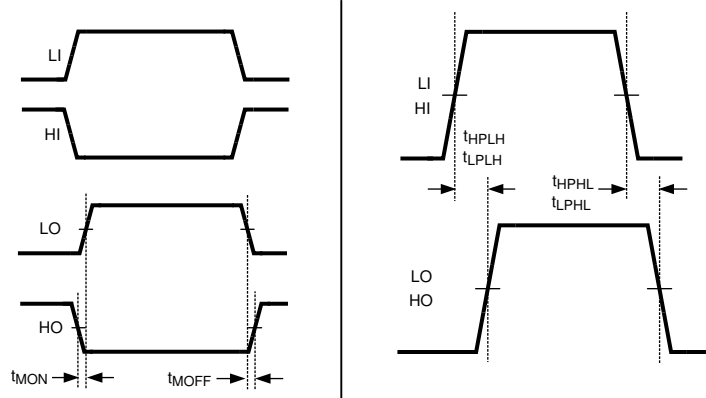


Figure 6-1. Timing Diagram

6.7 Typical Characteristics

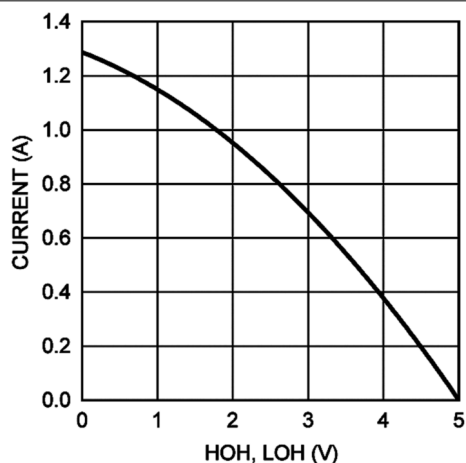


Figure 6-2. Peak Source Current vs Output Voltage

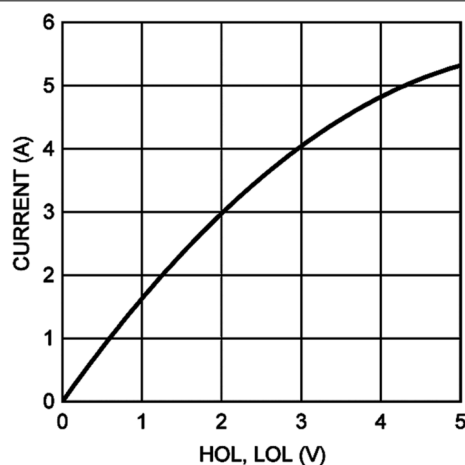
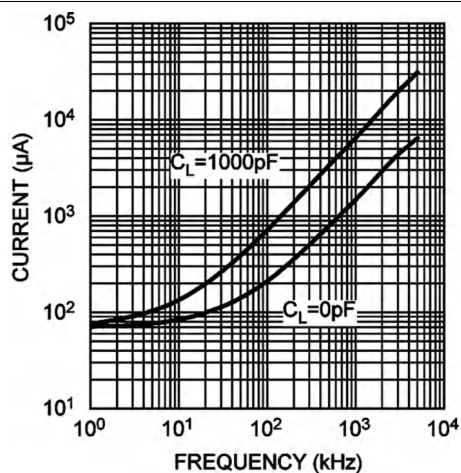
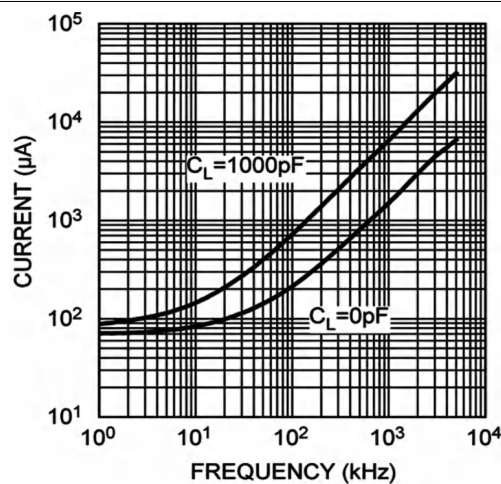


Figure 6-3. Peak Sink Current vs Output Voltage

Figure 6-4. I_{DDO} vs FrequencyFigure 6-5. I_{HBO} vs Frequency

6.7 Typical Characteristics (continued)

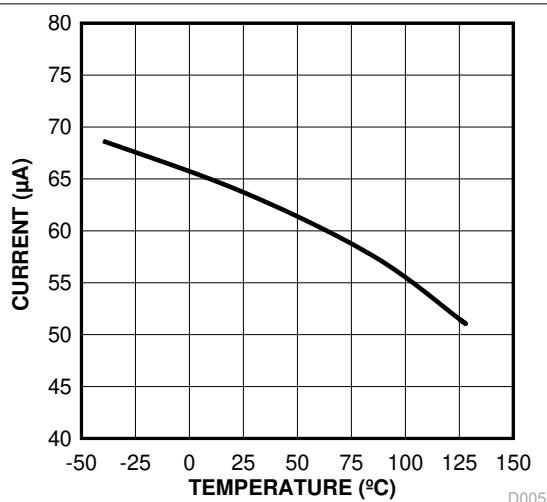


Figure 6-6. I_{DD} vs Temperature

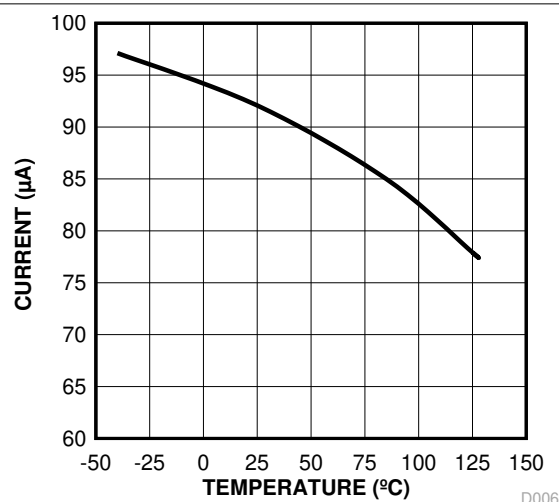


Figure 6-7. I_{HB} vs Temperature

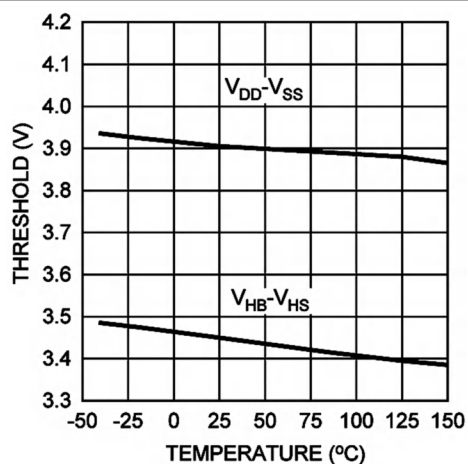


Figure 6-8. UVLO Rising Thresholds vs Temperature

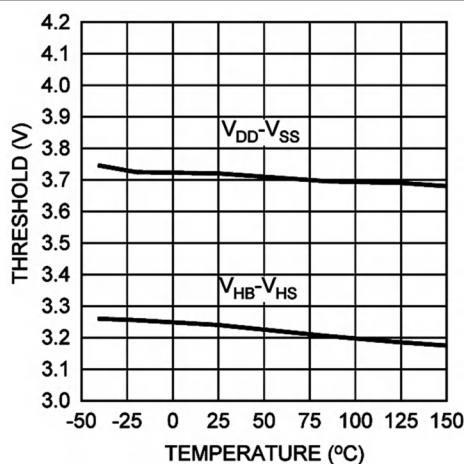


Figure 6-9. UVLO Falling Thresholds vs Temperature

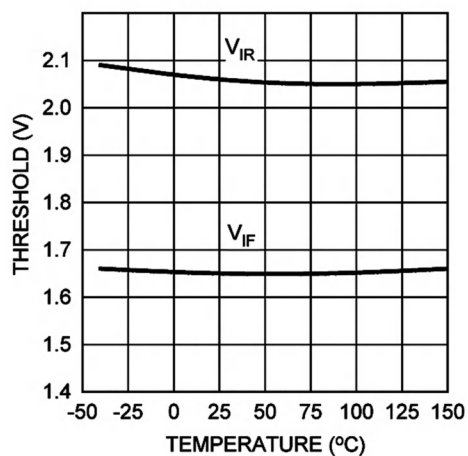


Figure 6-10. Input Thresholds vs Temperature

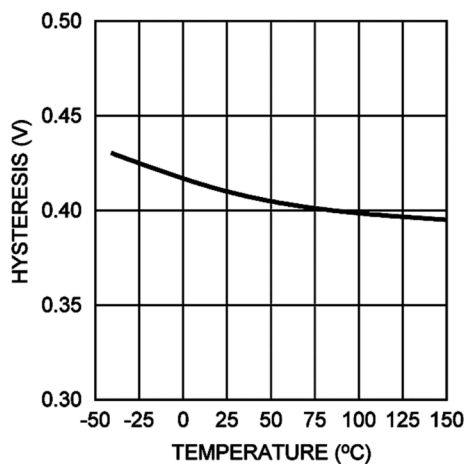


Figure 6-11. Input Threshold Hysteresis vs Temperature

6.7 Typical Characteristics (continued)

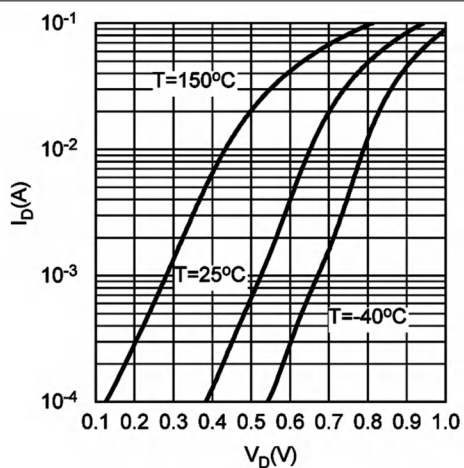


Figure 6-12. Bootstrap Diode Forward Voltage

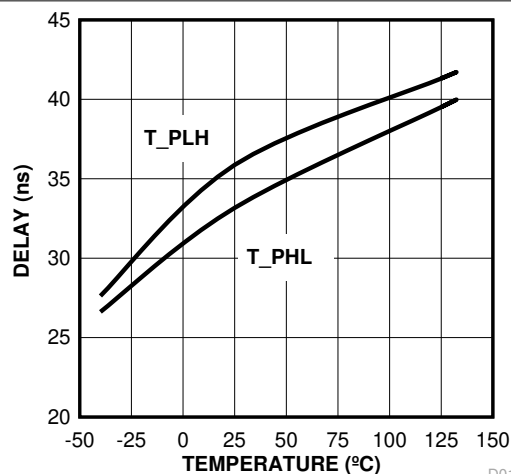


Figure 6-13. Propagation Delay vs Temperature

D012

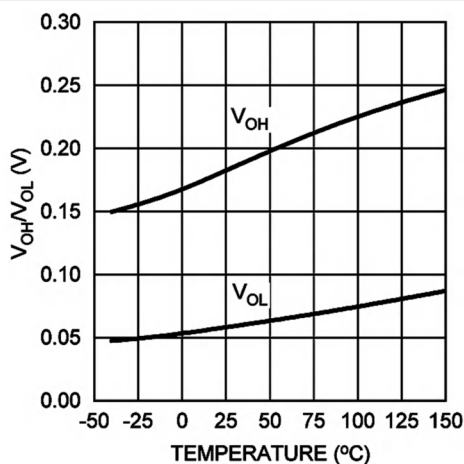


Figure 6-14. LO & HO Gate Drive – High/Low Level Output Voltage vs Temperature

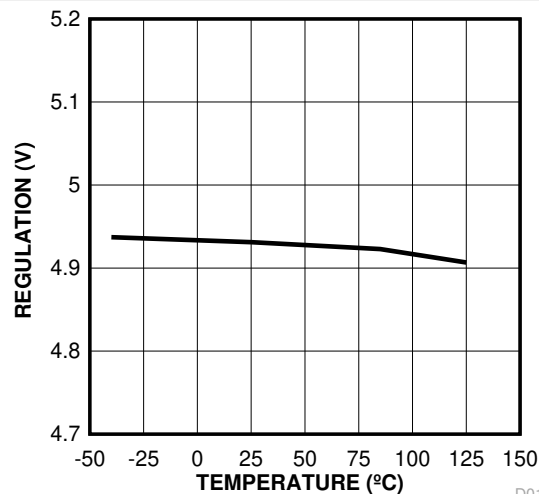


Figure 6-15. HB Regulation Voltage vs Temperature

D014

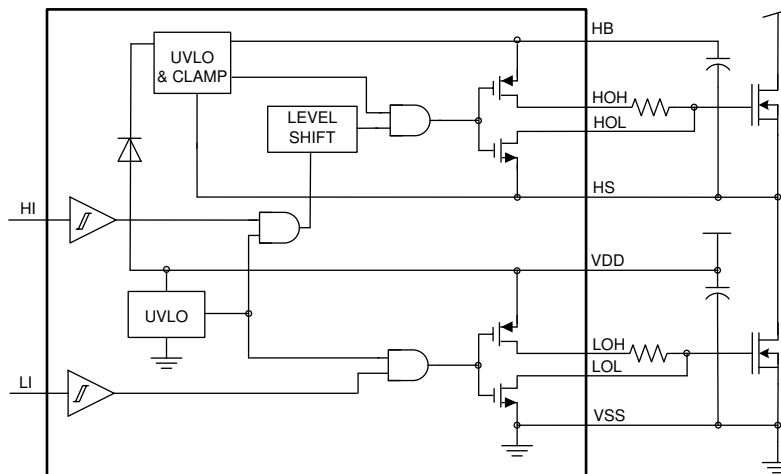
7 Detailed Description

7.1 Overview

The LMG1205 is a high frequency high- and low- side gate driver for enhancement mode Gallium Nitride (GaN) FETs in a synchronous buck, boost, or half-bridge configuration. The high-side bias voltage is generated using a bootstrap technique and is internally clamped at 5 V, which prevents the gate voltage from exceeding the maximum gate-source voltage rating of enhancement mode GaN FETs. The LMG1205 has split-gate outputs with strong sink capability, providing flexibility to adjust the turnon and turnoff strength independently.

The LMG1205 can operate up to several MHz, and is available in a 12-pin DSBGA package that offers a compact footprint and minimized package inductance.

7.2 Functional Block Diagram



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7.3 Feature Description

7.3.1 Input and Output

The input pins of the LMG1205 are independently controlled with TTL input thresholds and can withstand voltages up to 12 V regardless of the VDD voltage. This allows the inputs to be directly connected to the outputs of an analog PWM controller with up to 12-V power supply, eliminating the need for a buffer stage.

The output pulldown and pullup resistance of LMG1205 is optimized for enhancement mode GaN FETs to achieve high frequency and efficient operation. The 0.6-Ω pulldown resistance provides a robust low impedance turnoff path necessary to eliminate undesired turnon induced by high dv/dt or high di/dt. The 2.1-Ω pullup resistance helps reduce the ringing and over-shoot of the switch node voltage. The split outputs of the LMG1205 offers flexibility to adjust the turnon and turnoff speed by independently adding additional impedance in either the turnon path and/or the turnoff path.

If the input signal for either of the two channels, HI or LI, is not used, the control pin must be tied to either VDD or VSS. These inputs must not be left floating.

7.3.2 Start-up and UVLO

The LMG1205 has an undervoltage lockout (UVLO) on both the VDD and bootstrap supplies. When the VDD voltage is below the threshold voltage of 3.8 V, both the HI and LI inputs are ignored, to prevent the GaN FETs from being partially turned on. Also, if there is insufficient VDD voltage, the UVLO actively pulls the LOL and HOL low. When the VDD voltage is above its UVLO threshold, but the HB to HS bootstrap voltage is below the UVLO threshold of 3.2 V, only HOL is pulled low. Both UVLO threshold voltages have 200 mV of hysteresis to avoid chattering.

Table 7-1. VDD UVLO Feature Logic Operation

CONDITION ($V_{HB-HS} > V_{HBR}$ for all cases below)	HI	LI	HO	LO
$V_{DD} - V_{SS} < V_{DDR}$ during device start-up	H	L	L	L
$V_{DD} - V_{SS} < V_{DDR}$ during device start-up	L	H	L	L
$V_{DD} - V_{SS} < V_{DDR}$ during device start-up	H	H	L	L
$V_{DD} - V_{SS} < V_{DDR}$ during device start-up	L	L	L	L
$V_{DD} - V_{SS} < V_{DDR} - V_{DDH}$ after device start-up	H	L	L	L
$V_{DD} - V_{SS} < V_{DDR} - V_{DDH}$ after device start-up	L	H	L	L
$V_{DD} - V_{SS} < V_{DDR} - V_{DDH}$ after device start-up	H	H	L	L
$V_{DD} - V_{SS} < V_{DDR} - V_{DDH}$ after device start-up	L	L	L	L

Table 7-2. V_{HB-HS} UVLO Feature Logic Operation

CONDITION ($V_{DD} > V_{DDR}$ for all cases below)	HI	LI	HO	LO
$V_{HB-HS} < V_{HBR}$ during device start-up	H	L	L	L
$V_{HB-HS} < V_{HBR}$ during device start-up	L	H	L	H
$V_{HB-HS} < V_{HBR}$ during device start-up	H	H	L	H
$V_{HB-HS} < V_{HBR}$ during device start-up	L	L	L	L
$V_{HB-HS} < V_{HBR} - V_{HBH}$ after device start-up	H	L	L	L
$V_{HB-HS} < V_{HBR} - V_{HBH}$ after device start-up	L	H	L	H
$V_{HB-HS} < V_{HBR} - V_{HBH}$ after device start-up	H	H	L	H
$V_{HB-HS} < V_{HBR} - V_{HBH}$ after device start-up	L	L	L	L

7.3.3 HS Negative Voltage and Bootstrap Supply Voltage Clamping

Due to the intrinsic nature of enhancement mode GaN FETs, the source-to-drain voltage of the bottom switch is usually higher than a diode forward voltage drop when the gate is pulled low. This causes negative voltage on HS pin. Moreover, this negative voltage transient may become even more pronounced due to the effects of board layout and device drain/source parasitic inductances. With high-side driver using the floating bootstrap configuration, negative HS voltage can lead to an excessive bootstrap voltage, which can damage the high-side GaN FET. The LMG1205 solves this problem with an internal clamping circuit that prevents the bootstrap voltage from exceeding 5 V typical. The clamping circuit works by opening an internal switch in series with the internal bootstrap diode when the bootstrap voltage exceeds the threshold, preventing further charging. The clamping circuit has a delay of about 270 ns between the threshold being exceeded and charging being stopped. In addition, the clamping circuit is bypassed if an external bootstrap diode is used.

7.3.4 Level Shift

The level-shift circuit is the interface from the high-side input to the high-side driver stage which is referenced to the switch node (HS). The level shift allows control of the HO output, which is referenced to the HS pin and provides excellent delay matching with the low-side driver. Typical delay matching between LO and HO is around 1.5 ns.

7.4 Device Functional Modes

Table 7-3 shows the device truth table.

Table 7-3. Truth Table

HI	LI	HOH	HOL	LOH	LOL
L	L	Open	L	Open	L
L	H	Open	L	H	Open
H	L	H	Open	Open	L
H	H	H	Open	H	Open

8 Application and Implementation

Note

Information in the following applications sections is not part of the TI component specification, and TI does not warrant its accuracy or completeness. TI's customers are responsible for determining suitability of components for their purposes, as well as validating and testing their design implementation to confirm system functionality.

8.1 Application Information

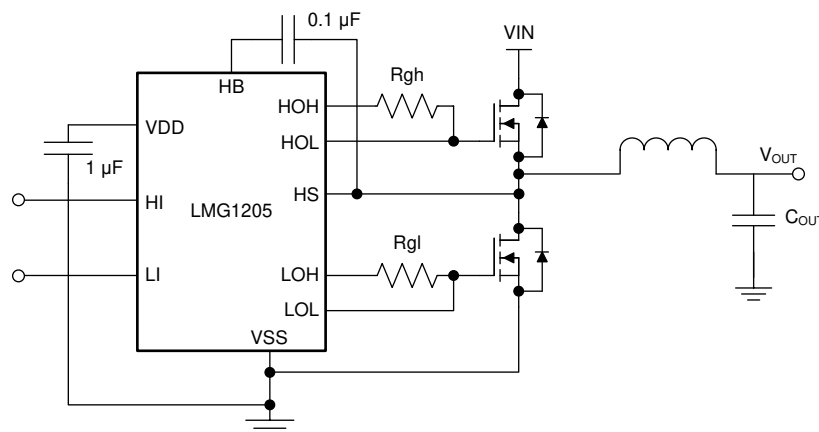
To operate GaN transistors at very high switching frequencies and to reduce associated switching losses, a powerful gate driver is employed between the PWM output of controller and the gates of the GaN transistor. Also, gate drivers are indispensable when the outputs of the PWM controller do not meet the voltage or current levels needed to directly drive the gates of the switching devices. With the advent of digital power, this situation is often encountered because the PWM signal from the digital controller is often a 3.3-V logic signal, which cannot effectively turn on a power switch. A level-shift circuit is needed to boost the 3.3 V signal to the gate-drive voltage (such as 12 V) in order to fully turn on the power device and minimize conduction losses.

Traditional buffer drive circuits based on NPN/PNP bipolar transistors in totem-pole arrangement prove inadequate with digital power because they lack level-shifting capability. Gate drivers effectively combine both the level-shifting and buffer-drive functions. Gate drivers also address other needs such as minimizing the effect of high-frequency switching noise (by placing the high-current driver IC physically close to the power switch), driving gate-drive transformers and controlling floating power-device gates, reducing power dissipation and thermal stress in controllers by moving gate charge power losses from the controller into the driver.

The LMG1205 is a MHz high- and low-side gate driver for enhancement mode GaN FETs in a synchronous buck, boost, or half-bridge configuration. The high-side bias voltage is generated using a bootstrap technique and is internally clamped at 5 V, which prevents the gate voltage from exceeding the maximum gate-source voltage rating of enhancement mode GaN FETs. The LMG1205 has split-gate outputs with strong sink capability, providing flexibility to adjust the turnon and turnoff strength independently.

8.2 Typical Application

The circuit in [Figure 8-1](#) shows a synchronous buck converter to evaluate LMG1205. Detailed synchronous buck converter specifications are listed in [Section 8.2.1](#). Optimization of the power loop (loop impedance from VIN capacitor to PGND) is critical to the performance of the design. Having a high power loop inductance causes significant ringing in the SW node and also causes an associated power loss. For more information, please refer to [Section 11.2.1](#).



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Figure 8-1. Application Circuit

8.2.1 Design Requirements

When designing a synchronous buck converter application that incorporates the LMG1205 gate driver and GaN power FETs, some design considerations must be evaluated first to make the most appropriate selection. Among these considerations are the input voltages, passive components, operating frequency, and controller selection. [Table 8-1](#) shows some sample values for a typical application. See [Section 9](#), [Section 10](#), and [Section 8.2.2.3](#) for other key design considerations for the LMG1205.

Table 8-1. Design Parameters

PARAMETER	SAMPLE VALUE
Half-bridge input supply voltage, V_{IN}	48 V
Output voltage, V_{OUT}	12 V
Output current	8 A
Dead time	8 ns
Inductor	4.7 μ H
Switching frequency	1 MHz

8.2.2 Detailed Design Procedure

This procedure outlines the design considerations of LMG1205 in a synchronous buck converter with enhancement mode GaN FET. For additional design help, see [Section 11.2.1](#).

8.2.2.1 VDD Bypass Capacitor

The VDD bypass capacitor provides the gate charge for the low-side and high-side transistors and to absorb the reverse recovery charge of the bootstrap diode. The required bypass capacitance can be calculated with [Equation 1](#).

$$C_{VDD} > \frac{Q_{gH} + Q_{gL} + Q_{rr}}{\Delta V} \quad (1)$$

where

- Q_{gH} and Q_{gL} are gate charge of the high-side and low-side transistors, respectively
- Q_{rr} is the reverse recovery charge of the bootstrap diode, which is typically around 4nC
- ΔV is the maximum allowable voltage drop across the bypass capacitor

TI recommends a 0.1- μ F or larger value, good-quality ceramic capacitor. The bypass capacitor must be placed as close as possible to the device pins to minimize the parasitic inductance.

8.2.2.2 Bootstrap Capacitor

The bootstrap capacitor provides the gate charge for the high-side switch, DC bias power for HB undervoltage lockout circuit, and the reverse recovery charge of the bootstrap diode. The required bypass capacitance can be calculated with [Equation 2](#).

$$C_{BST} > \frac{Q_{gH} + (I_{HB} + I_{GSS}) \times T_{ON} + Q_{rr}}{\Delta V} \quad (2)$$

where

- I_{HB} is the quiescent current of the high-side driver
- T_{on} is the maximum on-time period of the high-side transistor
- I_{GSS} is the gate leakage current of the high-side transistor

A good-quality ceramic capacitor must be used for the bootstrap capacitor. TI recommends placing the bootstrap capacitor as close as possible to the HB and HS pins.

8.2.2.3 Power Dissipation

The power consumption of the driver is an important measure that determines the maximum achievable operating frequency of the driver. It must be kept below the maximum power dissipation limit of the package at the operating temperature. The total power dissipation of the LMG1205 is the sum of the gate driver losses and the bootstrap diode power loss.

The gate driver losses are incurred by charge and discharge of the capacitive load. It can be approximated as

$$P = (C_{\text{LoadH}} + C_{\text{LoadL}}) \times V_{\text{DD}}^2 \times f_{\text{SW}} \quad (3)$$

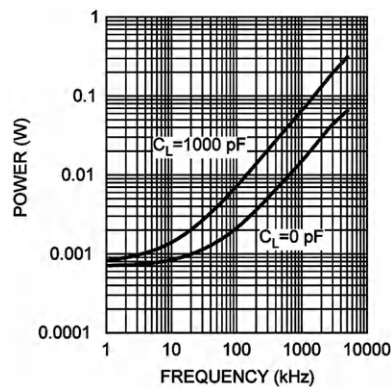
where

- C_{LoadH} and C_{LoadL} are the high-side and the low-side capacitive loads, respectively

It can also be calculated with the total input gate charge of the high-side and the low-side transistors as

$$P = (Q_{\text{gH}} + Q_{\text{gL}}) \times V_{\text{DD}} \times f_{\text{SW}} \quad (4)$$

There are some additional losses in the gate drivers due to the internal CMOS stages used to buffer the LO and HO outputs. Figure 8-2 shows the measured gate driver power dissipation versus frequency and load capacitance. At higher frequencies and load capacitance values, the power dissipation is dominated by the power losses driving the output loads and agrees well with the above equations. Figure 8-2 can be used to approximate the power losses due to the gate drivers.

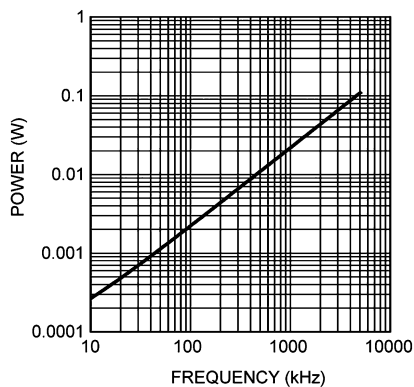


Gate driver power dissipation (LO+HO), VDD = 5 V

Figure 8-2. Neglecting Bootstrap Diode Losses

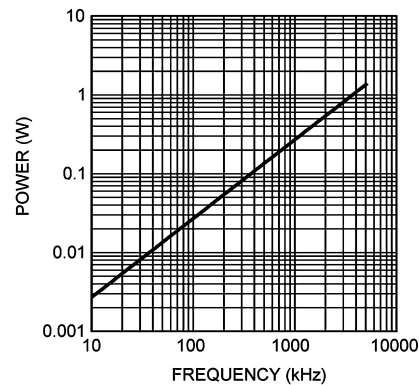
The bootstrap diode power loss is the sum of the forward bias power loss that occurs while charging the bootstrap capacitor and the reverse bias power loss that occurs during reverse recovery. Because each of these events happens once per cycle, the diode power loss is proportional to the operating frequency. Larger capacitive loads require more energy to recharge the bootstrap capacitor resulting in more losses. Higher input voltages (V_{IN}) to the half bridge also result in higher reverse recovery losses.

Figure 8-3 and Figure 8-4 show the forward bias power loss and the reverse bias power loss of the bootstrap diode respectively. The plots are generated based on calculations and lab measurements of the diode reverse time and current under several operating conditions. Figure 8-3 and Figure 8-4 can be used to predict the bootstrap diode power loss under different operating conditions.



The load of high-side driver is a GaN FET with total gate charge of 10 nC.

Figure 8-3. Forward Bias Power Loss of Bootstrap Diode $V_{IN} = 50$ V



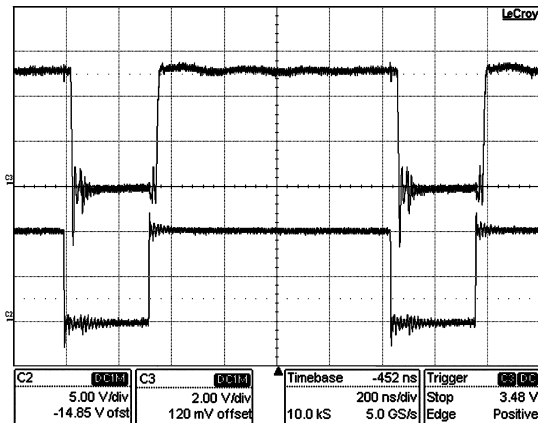
The load of high-side driver is a GaN FET with total gate charge of 10 nC.

Figure 8-4. Reverse Recovery Power Loss of Bootstrap Diode $V_{IN} = 50$ V

The sum of the driver loss and the bootstrap diode loss is the total power loss of the IC. For a given ambient temperature, the maximum allowable power loss of the IC can be defined as [Equation 5](#).

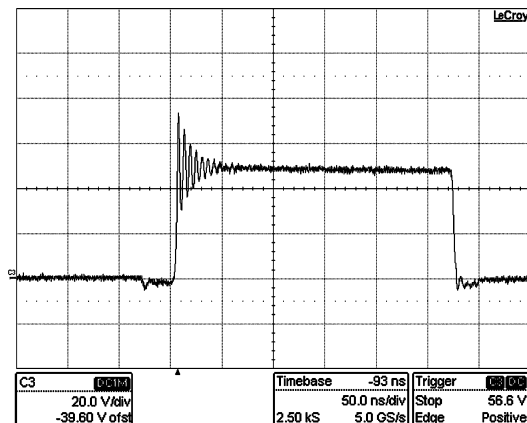
$$P = \frac{(T_J - T_A)}{\theta_{JA}} \quad (5)$$

8.2.3 Application Curves



Conditions: Input Voltage = 48 V DC, Load Current = 5 A
ATraces: Top Trace: Gate of Low-Side eGaN FET, Volt/div = 2 V Bottom Trace: LI of LMG1205, Volt/div = 5 V Bandwidth Limit = 600 MHz Horizontal Resolution = 0.2 μ s/div

Figure 8-5. Low-Side Driver Input and Output



Conditions: Input Voltage = 48 V DC, Load Current = 10 A
ATraces: Trace: Switch-Node Voltage, Volts/div = 20 V Bandwidth Limit = 600 MHz Horizontal Resolution = 50 ns/div

Figure 8-6. Switch-Node Voltage

9 Power Supply Recommendations

The recommended bias supply voltage range for LMG1205 is from 4.5 V to 5.5 V. The lower end of this range is governed by the internal UVLO protection feature of the VDD supply circuit. TI recommends keeping proper margin to allow for transient voltage spikes while not violating the LMG1205 absolute maximum VDD voltage rating and the GaN transistor gate breakdown voltage limit.

The UVLO protection feature also involves a hysteresis function. This means that once the device is operating in normal mode, if the VDD voltage drops, the device continues to operate in normal mode as far as the voltage drop does not exceed the hysteresis specification, VDDH. If the voltage drop is more than hysteresis specification, the device shuts down. Therefore, while operating at or near the 4.5-V range, the voltage ripple on the VDD power supply output must be smaller than the hysteresis specification of LMG1205 UVLO to avoid triggering device shutdown.

A local bypass capacitor must be placed between the VDD and VSS pins. This capacitor must be located as close as possible to the device. TI recommends a low-ESR, ceramic, surface-mount capacitor. TI also recommends using 2 capacitors across VDD and GND: a 100-nF ceramic surface-mount capacitor for high frequency filtering placed very close to VDD and GND pin, and another surface-mount capacitor, 220 nF to 10 μ F, for IC bias requirements.

10 Layout

10.1 Layout Guidelines

Small gate capacitance and Miller capacitance enable enhancement mode GaN FETs to operate with fast switching speed. The induced high dv/dt and di/dt , coupled with a low gate threshold voltage and limited headroom of enhancement mode GaN FETs gate voltage, make the circuit layout crucial to the optimum performance. Following are some recommendations:

1. The first priority in designing the layout of the driver is to confine the high peak currents that charge and discharge the GaN FETs gate into a minimal physical area. This decreases the loop inductance and minimize noise issues on the gate terminal of the GaN FETs. The GaN FETs must be placed close to the driver.
2. The second high current path includes the bootstrap capacitor, the local ground referenced VDD bypass capacitor and low-side GaN FET. The bootstrap capacitor is recharged on a cycle-by-cycle basis through the bootstrap diode from the ground referenced VDD capacitor. The recharging occurs in a short time interval and involves high peak current. Minimizing this loop length and area on the circuit board is important to ensure reliable operation.
3. The parasitic inductance in series with the source of the high-side FET and the low-side FET can impose excessive negative voltage transients on the driver. TI recommends connecting the HS pin and VSS pin to the respective source of the high-side and low-side transistors with a short and low-inductance path.
4. The parasitic source inductance, along with the gate capacitor and the driver pull-down path, can form an LCR resonant tank, resulting in gate voltage oscillations. An optional resistor or ferrite bead can be used to damp the ringing.
5. Low ESR/ESL capacitors must be connected close to the IC, between VDD and VSS pins and between the HB and HS pins to support the high peak current being drawn from VDD during turnon of the FETs. Keeping bullet #1 (minimized GaN FETs gate driver loop) as the first priority, it is also desirable to place the VDD decoupling capacitor and the HB to HS bootstrap capacitor on the same side of the PC board as the driver. The inductance of vias can impose excessive ringing on the IC pins.
6. To prevent excessive ringing on the input power bus, good decoupling practices are required by placing low-ESR ceramic capacitors adjacent to the GaN FETs.

Figure 10-1 and Figure 10-2 show recommended layout patterns for the LMG1205. Two cases are considered: (1) without any gate resistors, and (2) with an optional turnon gate resistor. Note that 0402 surface mount package is assumed for the passive components in the drawings. For information on DSBGA package assembly, refer to Section 11.2.1.

10.2 Layout Examples

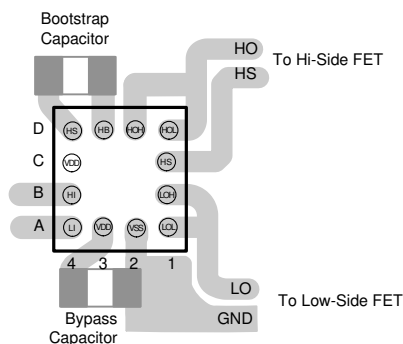


Figure 10-1. Layout Example Without Gate Resistors

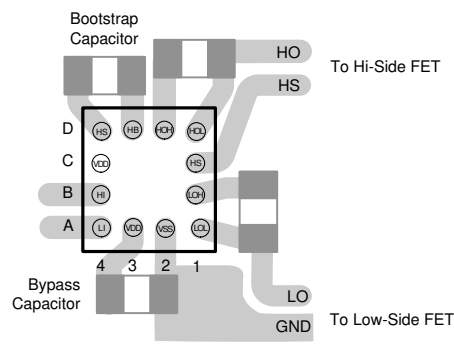


Figure 10-2. Layout Example with HOH and LOH Gate Resistors

11 Device and Documentation Support

11.1 Device Support

11.1.1 Third-Party Products Disclaimer

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11.2 Documentation Support

11.2.1 Related Documentation

For related documentation see the following:

- [AN-1112 DSBGA Wafer Level Chip Scale Package](#)
- [Using the LMG1205HBEVM GaN Half-Bridge EVM](#)

11.3 Receiving Notification of Documentation Updates

To receive notification of documentation updates, navigate to the device product folder on [ti.com](#). Click on *Subscribe to updates* to register and receive a weekly digest of any product information that has changed. For change details, review the revision history included in any revised document.

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ESD damage can range from subtle performance degradation to complete device failure. Precision integrated circuits may be more susceptible to damage because very small parametric changes could cause the device not to meet its published specifications.

11.7 Glossary

[TI Glossary](#) This glossary lists and explains terms, acronyms, and definitions.

Mechanical, Packaging, and Orderable Information

The following pages include mechanical, packaging, and orderable information. This information is the most current data available for the designated devices. This data is subject to change without notice and revision of this document. For browser-based versions of this datasheet, refer to the left-hand navigation.

PACKAGING INFORMATION

Orderable part number	Status (1)	Material type (2)	Package Pins	Package qty Carrier	RoHS (3)	Lead finish/ Ball material (4)	MSL rating/ Peak reflow (5)	Op temp (°C)	Part marking (6)
LMG1205YFXR	Active	Production	DSBGA (YFX) 12	3000 LARGE T&R	Yes	SNAGCU	Level-1-260C-UNLIM	-40 to 125	1205
LMG1205YFXR.A	Active	Production	DSBGA (YFX) 12	3000 LARGE T&R	Yes	SNAGCU	Level-1-260C-UNLIM	-40 to 125	1205
LMG1205YFXT	Active	Production	DSBGA (YFX) 12	250 SMALL T&R	Yes	SNAGCU	Level-1-260C-UNLIM	-40 to 125	1205
LMG1205YFXT.A	Active	Production	DSBGA (YFX) 12	250 SMALL T&R	Yes	SNAGCU	Level-1-260C-UNLIM	-40 to 125	1205

⁽¹⁾ **Status:** For more details on status, see our [product life cycle](#).

⁽²⁾ **Material type:** When designated, preproduction parts are prototypes/experimental devices, and are not yet approved or released for full production. Testing and final process, including without limitation quality assurance, reliability performance testing, and/or process qualification, may not yet be complete, and this item is subject to further changes or possible discontinuation. If available for ordering, purchases will be subject to an additional waiver at checkout, and are intended for early internal evaluation purposes only. These items are sold without warranties of any kind.

⁽³⁾ **RoHS values:** Yes, No, RoHS Exempt. See the [TI RoHS Statement](#) for additional information and value definition.

⁽⁴⁾ **Lead finish/Ball material:** Parts may have multiple material finish options. Finish options are separated by a vertical ruled line. Lead finish/Ball material values may wrap to two lines if the finish value exceeds the maximum column width.

⁽⁵⁾ **MSL rating/Peak reflow:** The moisture sensitivity level ratings and peak solder (reflow) temperatures. In the event that a part has multiple moisture sensitivity ratings, only the lowest level per JEDEC standards is shown. Refer to the shipping label for the actual reflow temperature that will be used to mount the part to the printed circuit board.

⁽⁶⁾ **Part marking:** There may be an additional marking, which relates to the logo, the lot trace code information, or the environmental category of the part.

Multiple part markings will be inside parentheses. Only one part marking contained in parentheses and separated by a "-" will appear on a part. If a line is indented then it is a continuation of the previous line and the two combined represent the entire part marking for that device.

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TAPE AND REEL INFORMATION



*All dimensions are nominal

Device	Package Type	Package Drawing	Pins	SPQ	Reel Diameter (mm)	Reel Width W1 (mm)	A0 (mm)	B0 (mm)	K0 (mm)	P1 (mm)	W (mm)	Pin1 Quadrant
LMG1205YFXR	DSBGA	YFX	12	3000	178.0	8.4	1.85	2.01	0.76	4.0	8.0	Q1
LMG1205YFXT	DSBGA	YFX	12	250	178.0	8.4	1.85	2.01	0.76	4.0	8.0	Q1

TAPE AND REEL BOX DIMENSIONS



*All dimensions are nominal

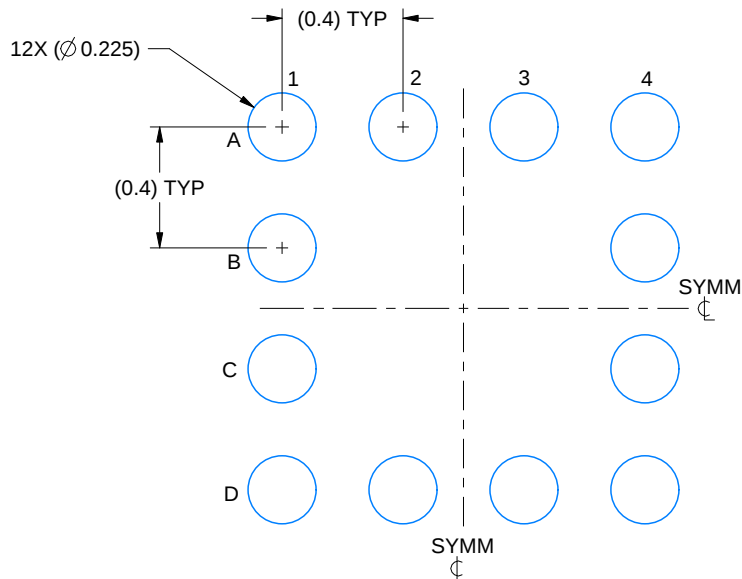
Device	Package Type	Package Drawing	Pins	SPQ	Length (mm)	Width (mm)	Height (mm)
LMG1205YFXR	DSBGA	YFX	12	3000	208.0	191.0	35.0
LMG1205YFXT	DSBGA	YFX	12	250	208.0	191.0	35.0

EXAMPLE BOARD LAYOUT

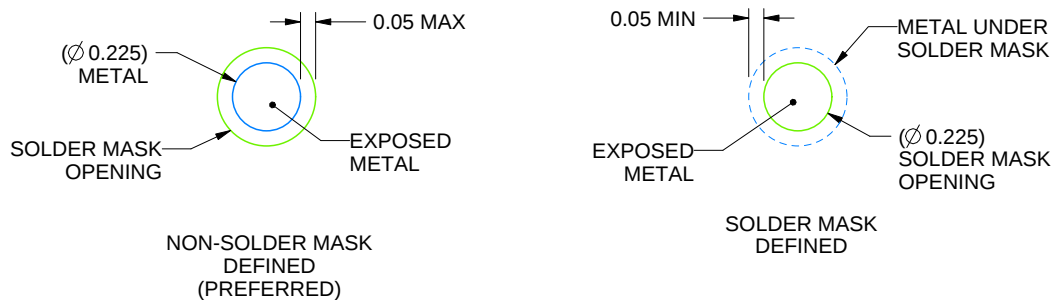
YFX0012

DSBGA - 0.675 mm max height

DIE SIZE BALL GRID ARRAY



LAND PATTERN EXAMPLE
EXPOSED METAL SHOWN
SCALE: 40X



SOLDER MASK DETAILS
NOT TO SCALE

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NOTES: (continued)

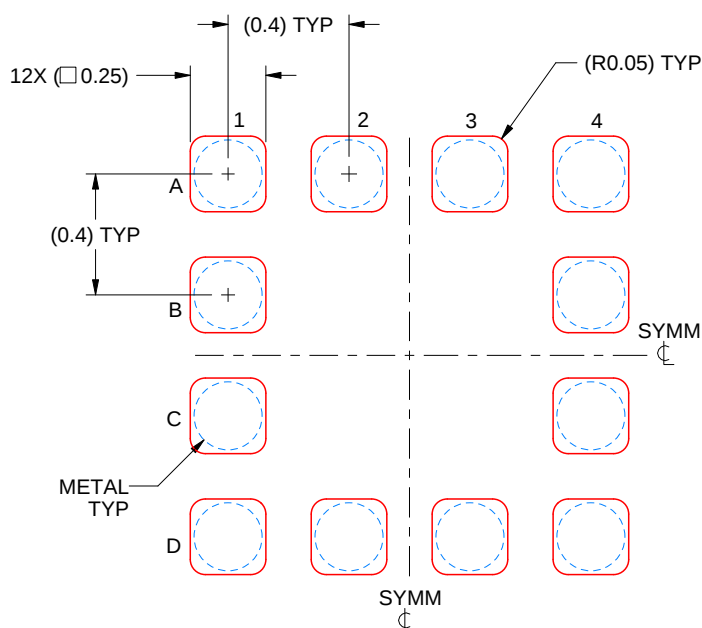
3. Final dimensions may vary due to manufacturing tolerance considerations and also routing constraints.
See Texas Instruments Literature No. SNVA009 (www.ti.com/lit/snva009).

EXAMPLE STENCIL DESIGN

YFX0012

DSBGA - 0.675 mm max height

DIE SIZE BALL GRID ARRAY



SOLDER PASTE EXAMPLE
BASED ON 0.1 mm THICK STENCIL
SCALE: 40X

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NOTES: (continued)

4. Laser cutting apertures with trapezoidal walls and rounded corners may offer better paste release.

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